UK Accelerator Institute Seminar



R&D of normal conducting VHF gun at Tsinghua University

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Outline



- 1. Introduction
- 2. R&D of the VHF gun
 - 2.1 Design and optimization
 - 2.2 Manufacturing and cold testing
 - 2.3 RF conditioning and beam testing
- 3. Summary and outlook

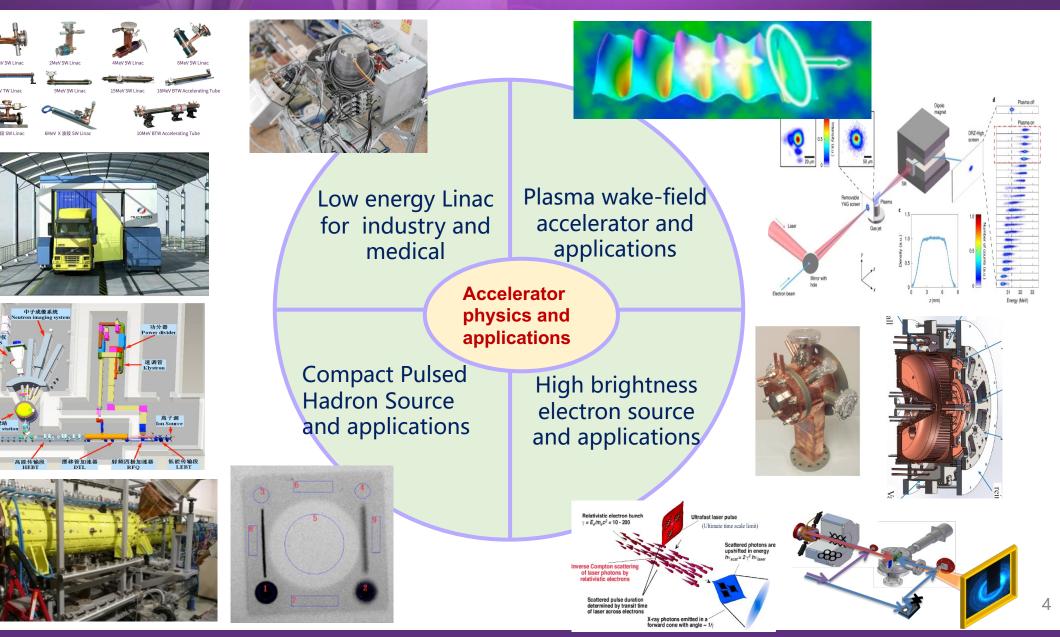


- Founded in 1956
- 17 faculties, ~10postdocs and more employees
- More than 60 graduate students





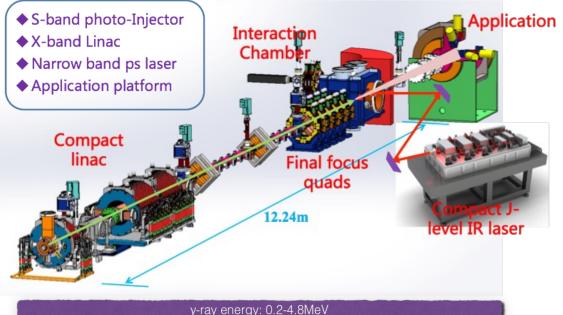
Accelerator Lab at Tsinghua University





Accelerator Lab at Tsinghua University

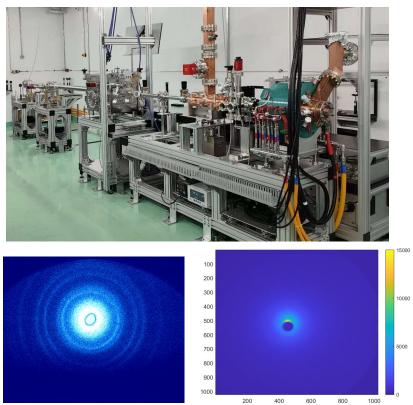
- High brightness electron source and applications (from 2001-now)
 - Inverse Compton scattering (Thomson scattering) X/γ-ray source



γ-ray energy: 0.2-4.8MeV Bandwidth with collimator : <1.5% Total photon flux(ph/s): >4×10^e@0.2-2.4MeV; >1×10^e@2.4-4.8MeV Photon flux with 1.5% Bandwidth(ph/s): >4×10^e@0.2-2.4MeV; >1×10^e@2.4-4.8MeV controllable polarization from linear to circle

VIGAS: very compact inverse Compton scattering gamma-ray source

 MeV Ultrafast electron diffraction and Microscopy



FORTRESS :Facility fOr Relativistic Time-Resolved Electron Sources and Scattering



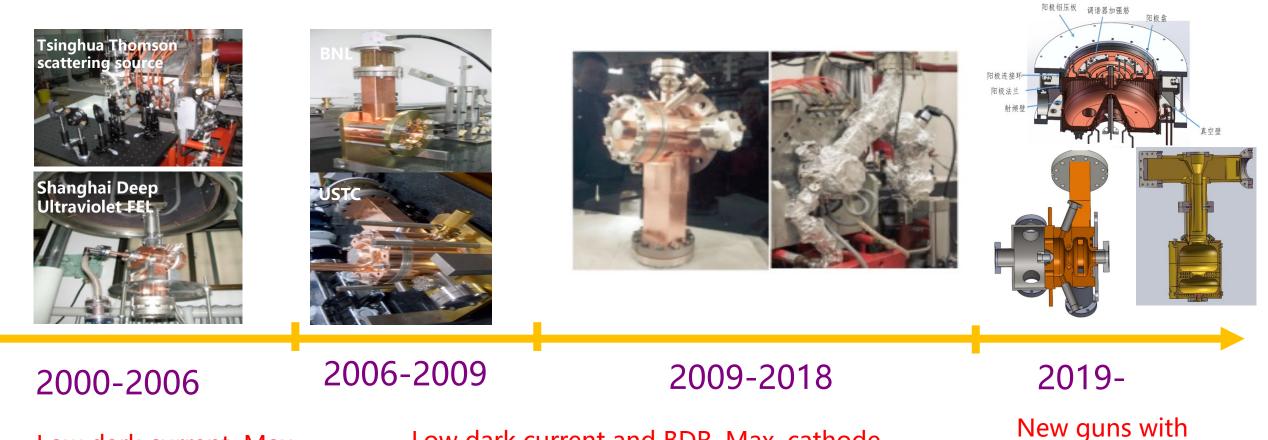
R&D of the photocathode RF gun at Tsinghua

semiconductor cathode

for middle or high

repetition-rate beam

More than 30 photocathode RF guns were made at THU

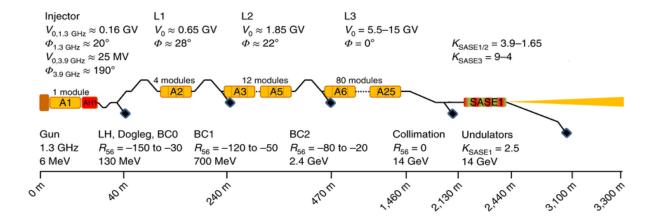


Low dark current, Max. cathode filed: 80-110MV/m Collaboration with BNL Low dark current and BDR, Max. cathode filed: 100-120MV/m, successfully applied at TTX, DCLS,SXFEL, etc. al



Gun's requirements for high repetition XFEL

• High repetition XFEL facilities



European XFEL:

Accelerator technology: Super-conducting Maximum beam energy: 17.5GeV Minimum wavelength: 0.05nm(25keV) Number of light flashes: 27,000 (2700x10)



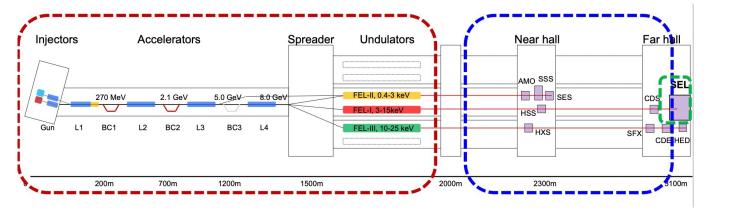
LCLS-II SCRF XFEL:

Accelerator technology: Super-conducting Maximum beam energy: 5 GeV Minimum wavelength: 0.25nm(5keV) Number of light flashes: 1,000,000



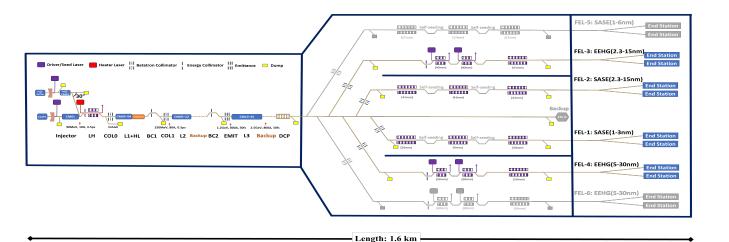
Gun's requirements for high repetition XFEL

• High repetition XFEL facilities in China



Shanghai High Repetition Rate XFEL and Extreme Light Facility(SHINE) :

Accelerator technology: Super-conducting Maximum beam energy: 8 GeV Minimum wavelength: 0.05nm(25keV) Number of light flashes: 1,000,000



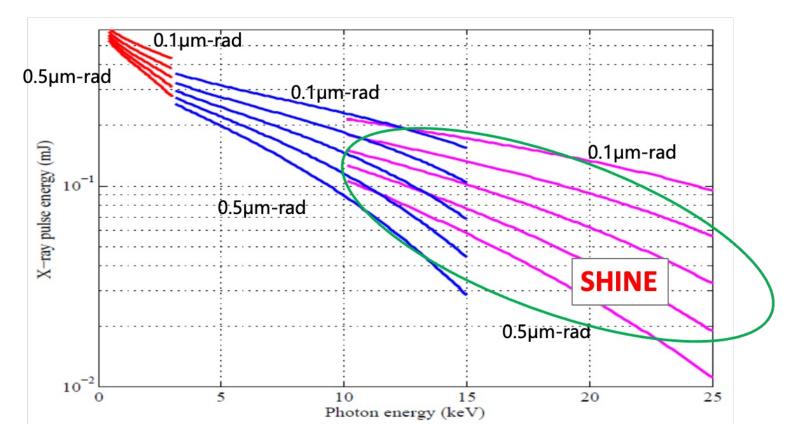
Shenzhen Superconducting Soft-Xray Free Electron Laser(S³FEL) :

Accelerator technology: Super-conducting Maximum beam energy: 2.5 GeV Minimum wavelength: 1nm(1.2keV) Number of light flashes: 1,000,000



Requirements on SHINE injector Courtesy: H. Deng

For SHINE: need to be better than 0.4 mm.mrad to get enough photons



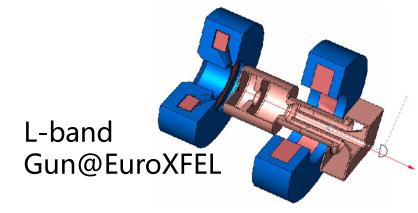
- CW operation
- 1 MHz repetition
- High charge, 20-300pC
- Low emittance,

<0.4um@100pC

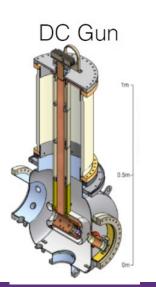


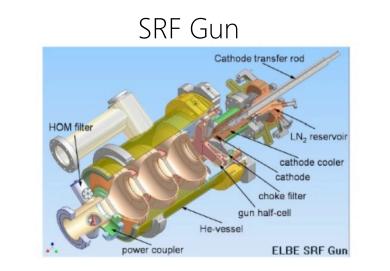
Gun's requirements for high repetition XFEL

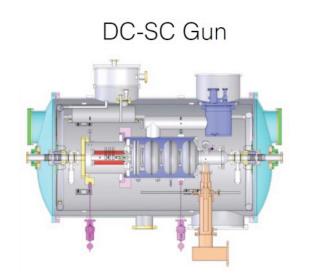
• Different guns can support MHz-class repetition-rate FELs



- > Operated in long pulsed mode
- > 4.5 MHz electron bunches in an rf pulse.
- > 27,000 electron bunches can be produced per second.
- Guns can be operated in CW mode





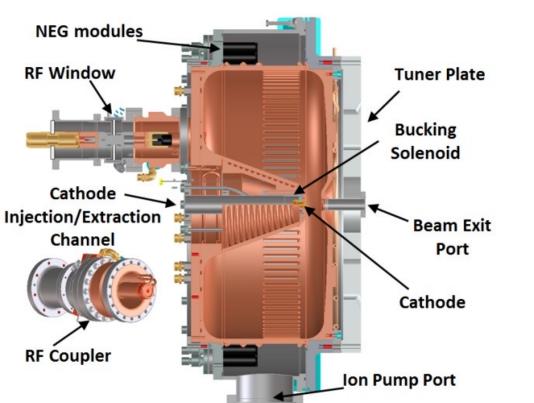


Gun's for LCLS-II SCRF





• VHF photocathode gun: Baseline for SHINE and S³FEL project



APEX-gun@LBNL

- Advantages:
 - Normal conducting
 - High cathode gradient and cavity voltage
 - long wavelength, big size, low temperature increase, CW operation
 - Good vacuum performance, successfully operated with semiconductor cathode
 - Demonstrated for stable CW operation and MHz repetition rate beam generation at LBNL and SLAC
 - 2019, MOU signed between Tsinghua and SHINE

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• **Design goal:** small beam emittance, high beam brightness

• Gun frequency: 216.7 MHz

216.7 MHz (1300MHz/6) or 162 MHz (1300MHz/8) is compatible with SHINE timing system. The gun with higher frequency is more compact and possible higher cathode gradient

• Cathode gradient: up to 30 MV/m

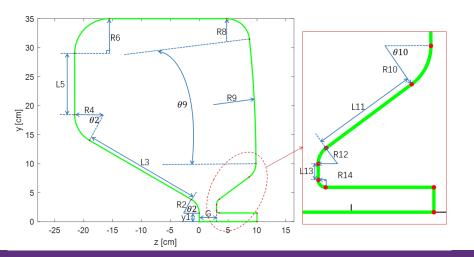
Higher gradient for beam brightness are expected. Higher gradient means higher dark current, high surface power density

- Gun voltage: \geq 750 kV, as higher as possible, achieved in APEX gun
- **RF power:** < **100 kW**, limited by RF power source and windows
- Max. wall power density: <30 W/cm² , limited by water cooling capacity

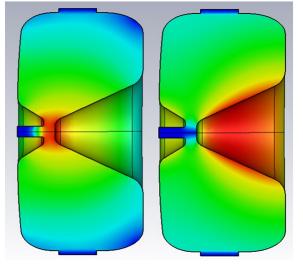


Gun design and optimization

- Optimized with CST:
 - Inner shape is parameterized and optimized in CST, especially for cathode nose and anode nose
 - Design objectives: fixed cathode gradient, max. surface field ↓, max. wall power density ↓, RF power ↓, gun voltage ↑
 - Multipacting
 - Dark-current



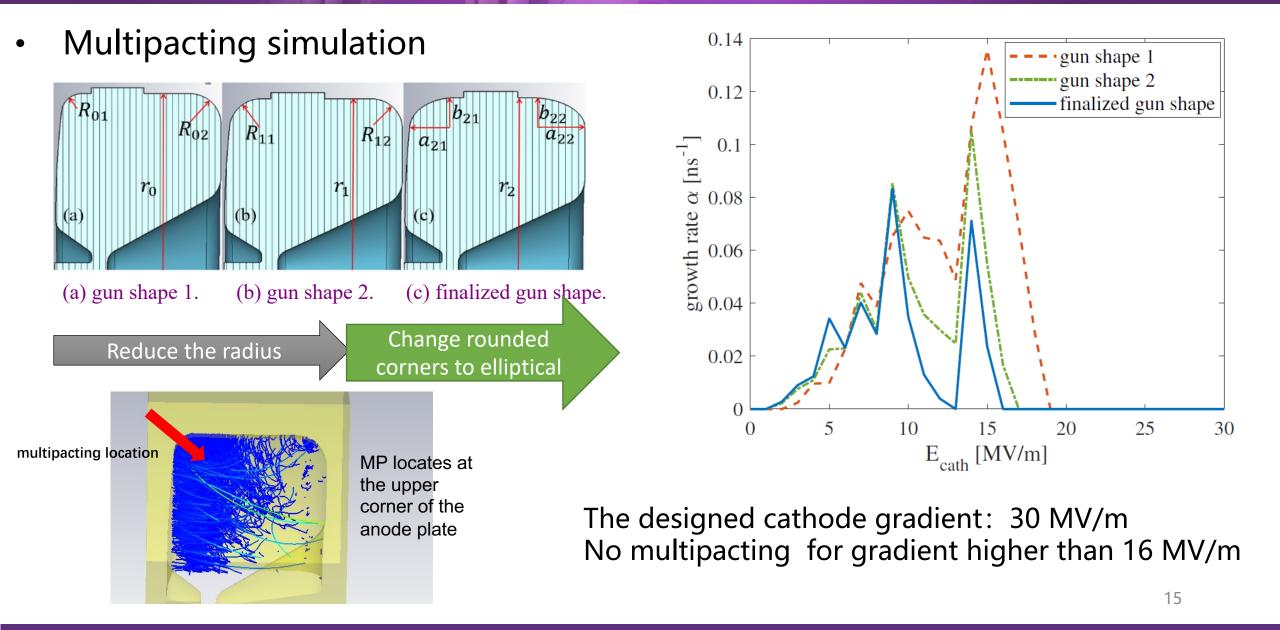
RF parameters	VHF Gun@THU	
Frequency	216.67 MHz	
Cathode gradient	30 MV/m	
Input RF power	90.4 kW	
Max. E field	36.99 MV/m (<2.5kilp)	
Max. P density	28.45 W/cm ²	
Voltage	868 kV	



E field H field



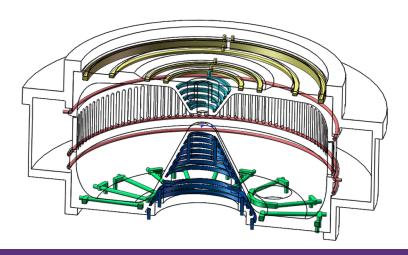
Gun design and optimization

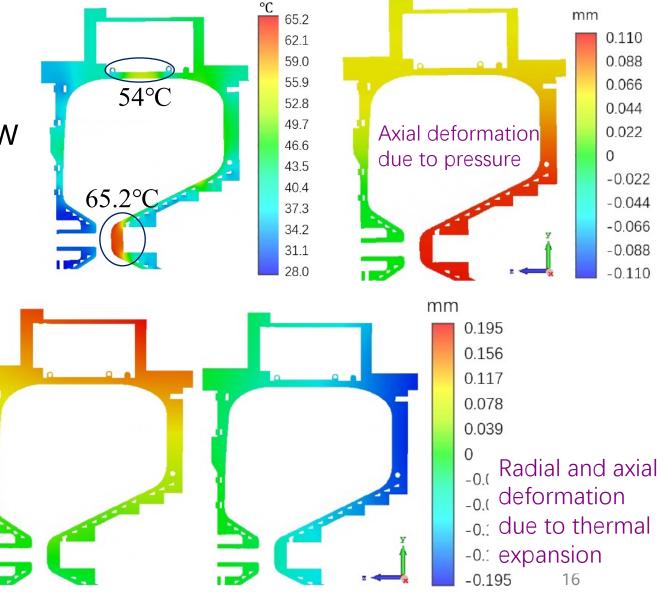




VHF gun RF design and optimization

- Cooling channels design
 - 23 independent water cooling pipes
 - Maximum temperature rise < 40°C@90kW
 - Deformation due to vacuum and RF heating is less than 200 um
 - Frequency detuning due to RF heating<80kHz



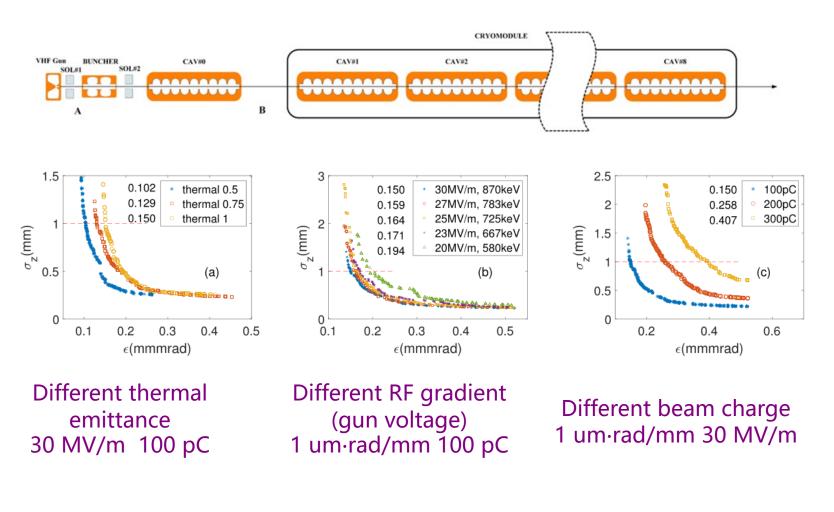




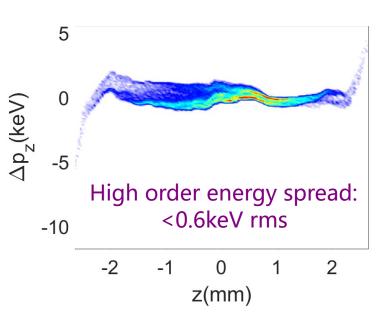
Gun design and optimization

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Beam dynamics simulation and optimization



- MOGA with Astra, fourteen parameters
 - Objectives: Low beam emittance and high order energy spread with 1mm rms bunch length



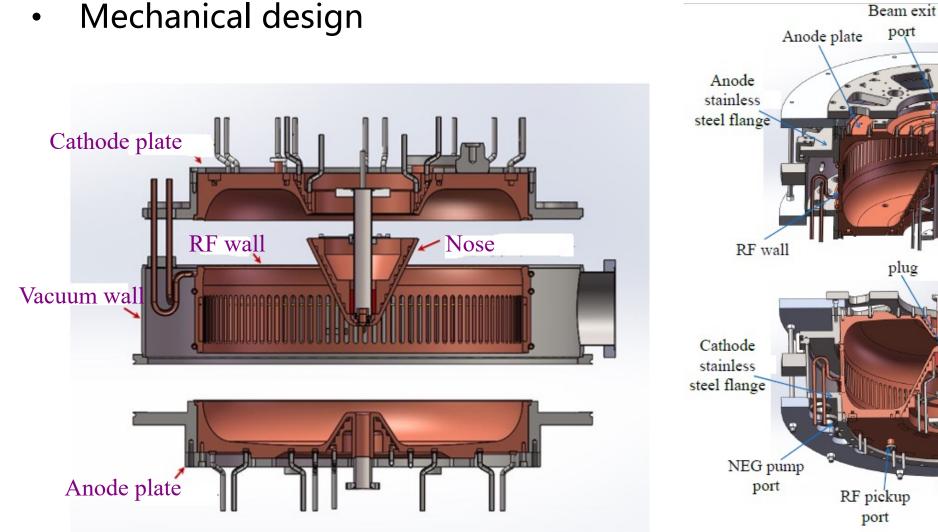
Outline

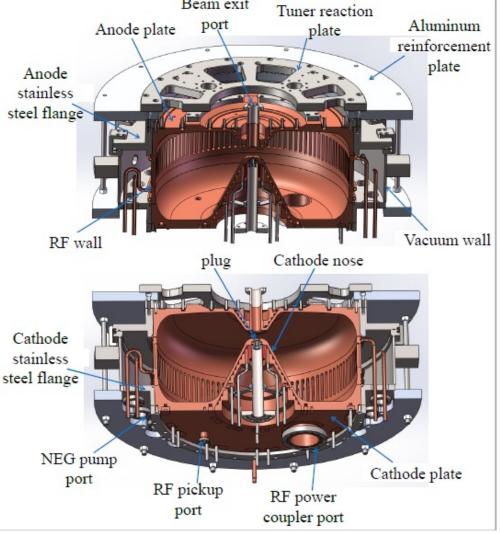


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Main components of gun

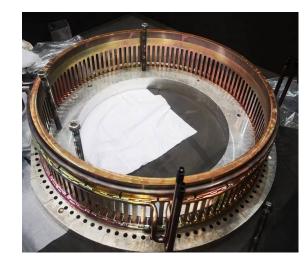




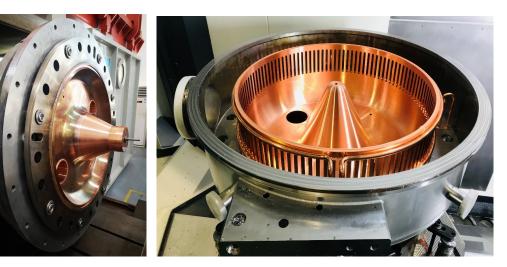


Machining of the VHF gun









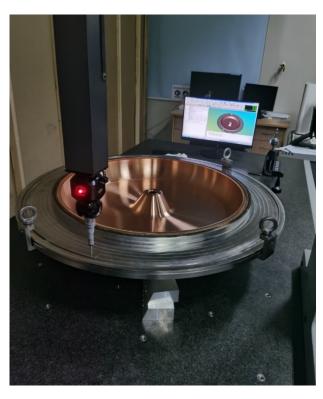


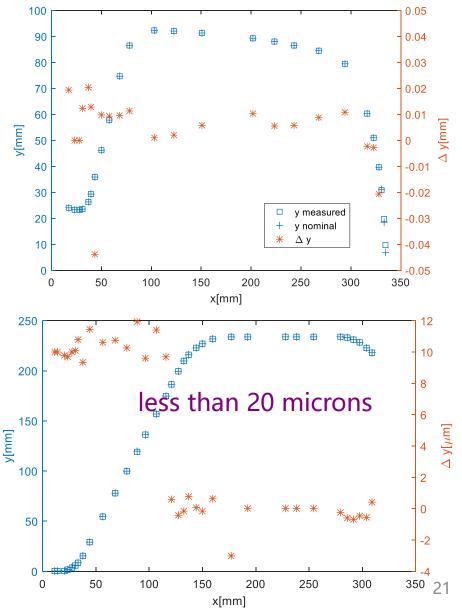


Machining of the VHF gun

 Inner profile is measured using a threecoordinate instrumentation, the error is less than 20 microns









Machining of the VHF gun

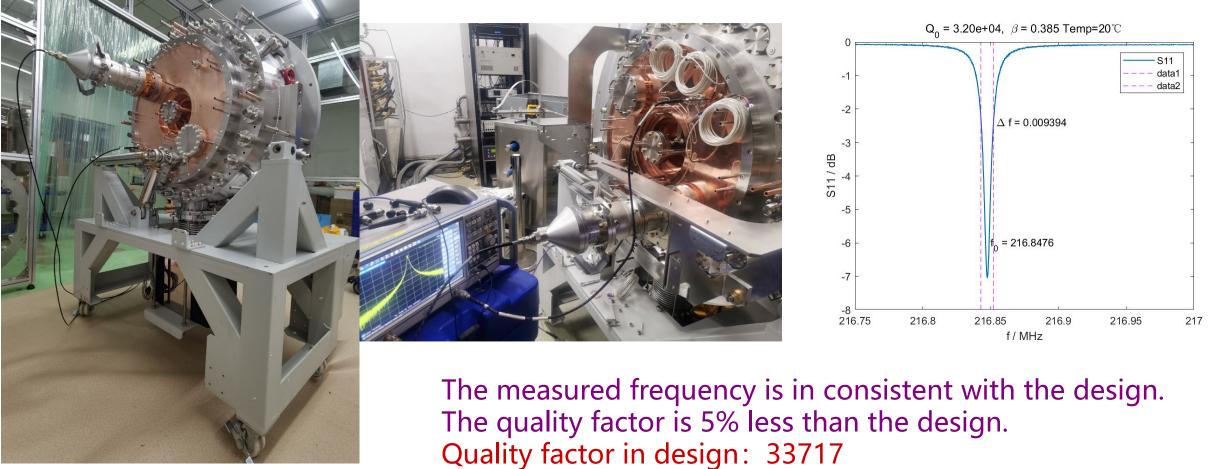
• Manual mechanical polishing of copper surface, roughness of the copper surface is less than R0.05







Cold testing of the VHF gun



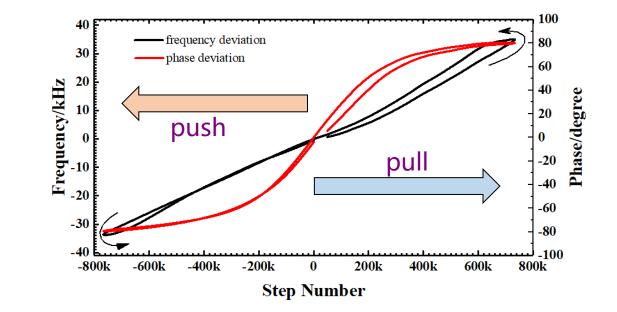
Quality factor measured: >32000



Cold testing of the VHF gun

• Tuner test





- The frequency shifts from -30 kHz to 30 kHz when the force of a single tuner scans from -3 kN to 3 kN. The frequency shift sensitivity is 2.5 kHz/kN.
- The maximum total force of the four tuners is (-40 kN, 40 kN), thus the maximum frequency shift is (-100 kHz, 100 kHz)

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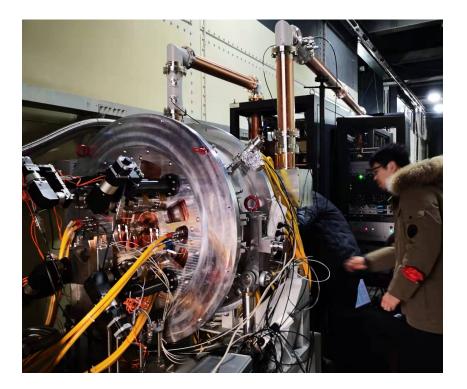
2.3 Conditioning and beam testing results

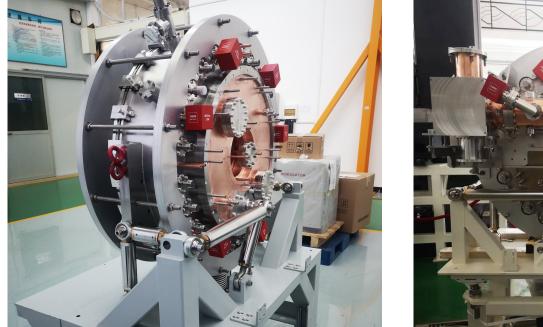
3. Summary and outlook



High power testing

• 3 guns have been made for process testing and beam commissioning





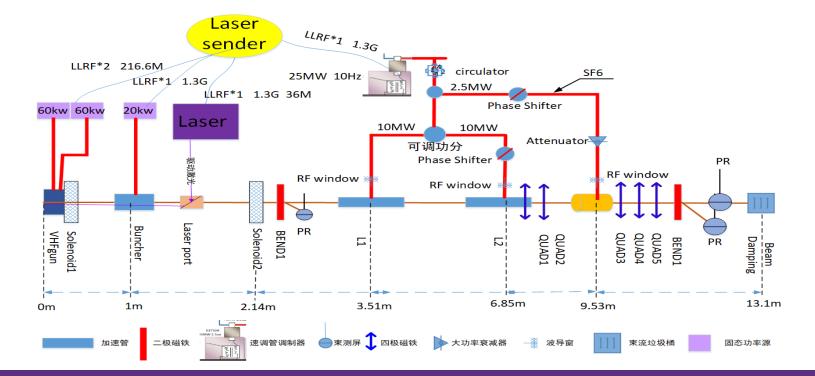
Prototype gun for machining process testing

Gun 2 and 3, >75kW CW stable operation(limited by power supply system) with low dark current



High power testing

- 30MeV beamline for gun beam testing
- One 400kV Buncher powered by 20kW SSA
- Two tubes and one deflecting cavity powered by a 20MW klystron operated in pulse mode.



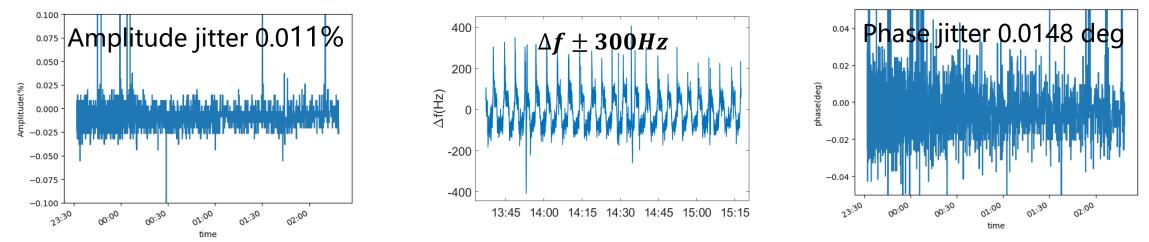






High power testing

 After ~20 hours RF commissioning, successfully operated in CW mode at 216.667 MHz with ~75 kW input power(limited by power supply system), or ~800kV voltage

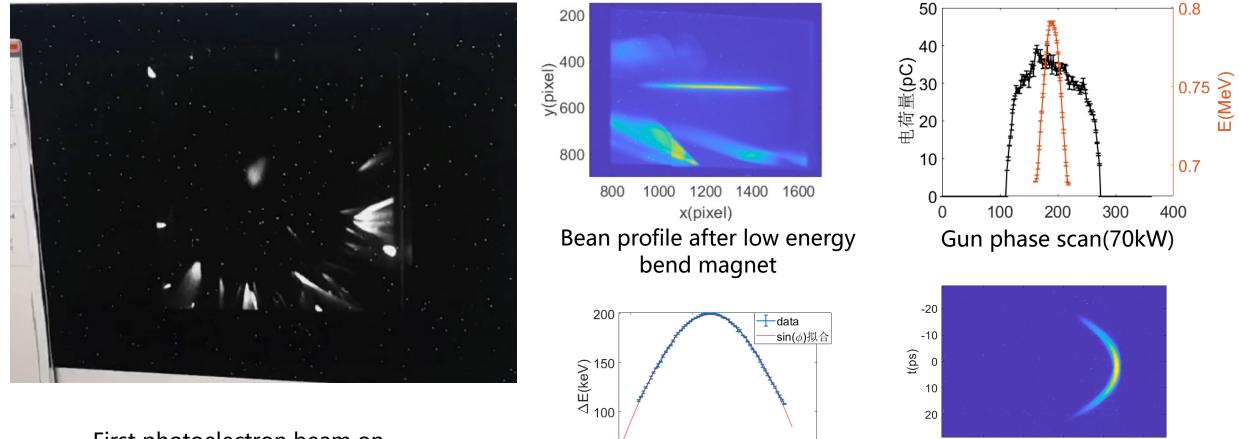


- Multipacting is observed with RF power lower than 25kW, which is in consistent with the simulation results.
- Good vacuum achieved in testing: ~ $2.0x10^{-8}$ pa without RF, ~ $9x10^{-8}$ pa with 75kW CW RF power.



Beam testing

• First photoelectron beam generated with Cs₂Te cathode on August 23, 2022.



50

50

100

聚束腔相位(deg)

Buncher on@~6kW

150

200

First photoelectron beam on 23 August, 2022, QE: ~1%

Deflecting cavity ON

E(MeV)

26.8

27.2

27

26.6

26.2

26.4



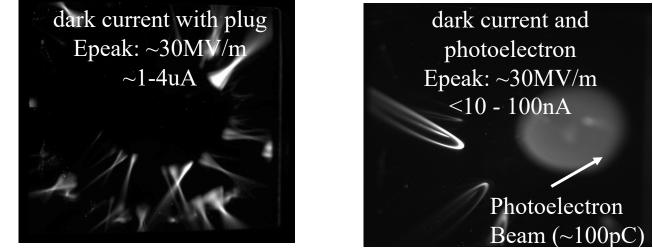
- Emittance measurement and optimization(preliminary results)
- No-ideal distribution of laser, dipole and quadrupole field in solenoid and RF structures, alignment

Bunch charge	Projected emittance $(um \cdot rad)$	(95%) Slice emittance $(um \cdot rc)$	
10 pC	0.16	0.15	0.49
50 pC	0.41	0.38	1.15
100 pC	0.85	0.72	envelope-x vs quad
⁵ - 1	elope-x vs quad OPC 58 ± 0.005mm.mrad 2 3 3.5 4 I(A)	x10 ⁻³ envelope-x vs quad 50pC $\epsilon_x = 0.407 \pm 0.0109mm.mrdd$ $\epsilon_x = 0.407 \pm 0.0109mm.mrdd$	$(1000 \text{ pc} \times 100 \text{ quad})$



- Dark current
 - High dark current during the first round running, 1-10uA
 - Significantly reduced after re-cleaning, less than 10nA with plug in.
 - Obvious dark current increasing from 10nA->~400nA during CW operation in about two months. And it also reduced to very low after re-processed.
 - Contamination (or dust) from cathode plug or downstream beam pipe?
 - In-situ cleaning technologies are necessary for long term operation.





Dark current of the 2nd gun, without(left) or with plug in(mid), and after re-processed



SHINE VHF gun Progress

 2023.04 Tsinghua VHF gun was delivered to SHINE project and installed as the first beam line component in tunnel.

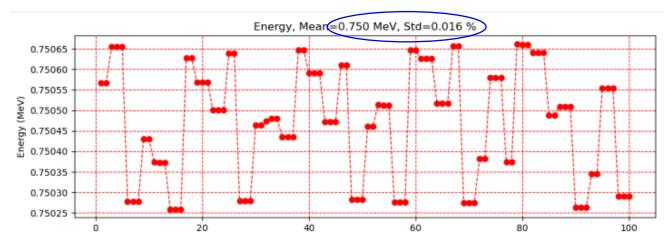




Gun installation and commissioning

Progress in 2023

- 2023.04, VHF gun delivered by Tsinghua team
- 2023.06, Cathode loadlock installed
- 2023.08, Gun section beamline installed
- 2023.10, Gun and buncher CW RF commissioning
- 2023.12, Gun section beam commissioning started



Courtesy of Houjun, SHINE

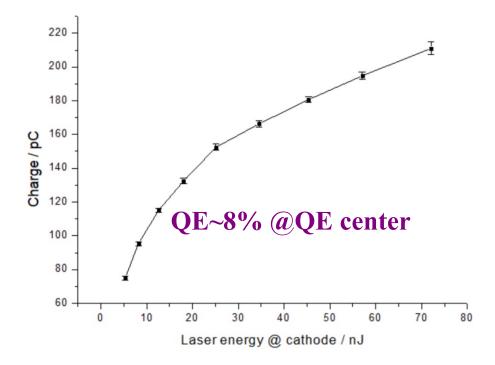




Gun beam commissioning

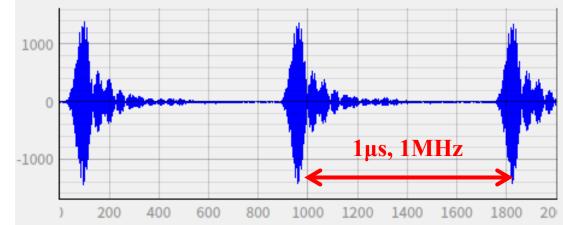
Cathode emission curve and QE

• Gaussian laser both in x and t





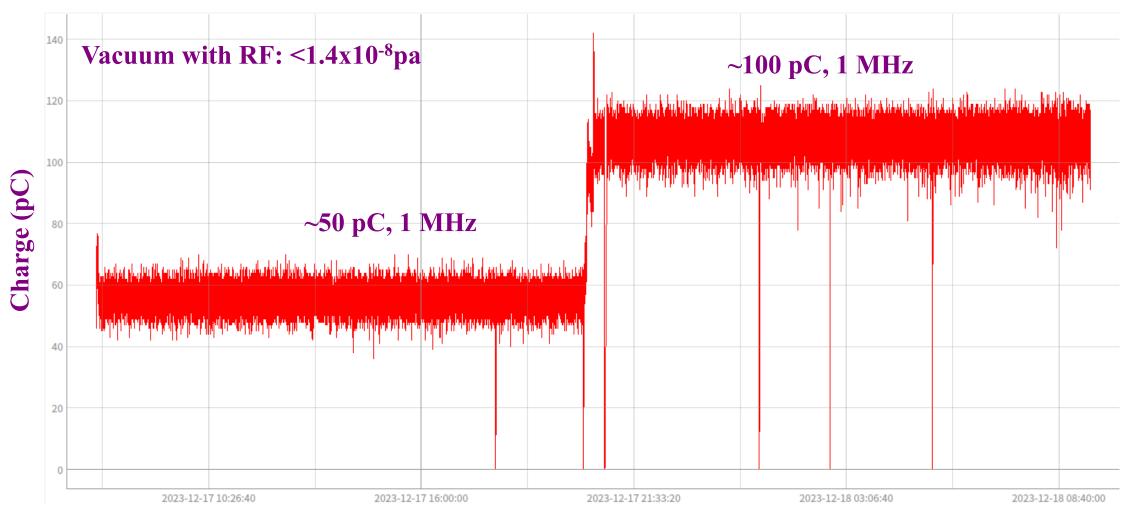




BPM ADC signal



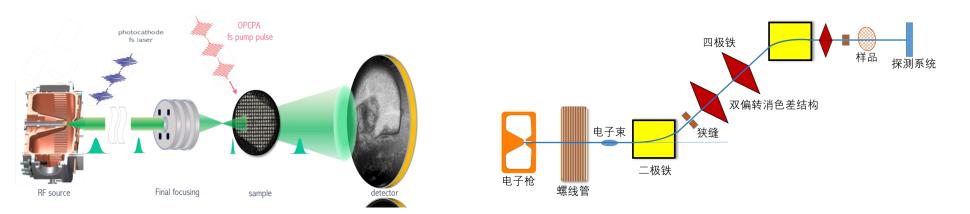
Gun beam commissioning



24-hour run, slow charge feedback on



- We successfully developed and delivered the VHF gun for SHINE project
- Further improve the gun performance and beam quality
 - Increase cathode gradient to 30MV/m, MHz repetition beam .
 - Beam emittance optimization.
 - New cathode testing with higher performance (green cathode).
 - In situ gun cleaning technologies.
- Applications with high repetition rate and high quality beam
 - High repetition MeV ultrafast electron diffraction and microscopy





Acknowledgement

- Collaborations and discussions with many colleagues
 - SHINE group
 - DCLS group from DICP CAS
 - S³FEL group from ISAF
 - Peking University
 - IHEP
 - •••••

